



AFTER FINAL

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

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6/7/07

Won-Sang SONG et al.

Art Unit: 2826

Serial No.: 10/823,544

Examiner: Tuan N. Quach

Filed: April 14, 2004

Confirmation No.: 4407

For: SEMICONDUCTOR DEVICE HAVING A METAL
SILICIDE LAYER AND METHOD FOR
MANUFACTURING THE SAME

Attorney Docket No.: 253/007 DIV

AMENDMENT UNDER 37 C.F.R. § 1.116

Mail Stop: BOX AF
Commissioner for Patents
United States Patent and Trademark Office
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Sir:

INTRODUCTORY COMMENTS

In response to the Office Action Made Final mailed March 29, 2007, the following amendments and remarks are respectfully submitted in connection with the above-identified application:

Amendments to the Claims are reflected in a listing of claims, which begins on page 2 of this paper.

Remarks begin on page 8 of this paper.

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